

**CZECH SOCIETY OF COSMETOLOGY**

*member of IFSCC established in 1956*

# **INTERNATIONAL CONFERENCE ON COSMETOLOGY**

**MIKULOV 2017**

**Hotel Galant Mikulov 4. – 6. October 2017**



**In cooperation with:**

**Slovak Society of Cosmetology** *Member of IFSCC*  
**University of Chemistry and Technology, Prague**

**General Sponsor: Chemotex Děčín a.s.**



Vysoká škola  
Chemicko technologická  
V Praze



# OUTLINE OF THE PROGRAMME AND A SCIENTIFIC COMMITTEE

## Wednesday, October 4, 2017

From 14:00 registration in the hotel  
19:00 invitation dinner

## Thursday, October 5, 2017

8:30 registration  
9:00 opening of the conference  
9:30 - 13:00 lectures, commercial presentations  
14:00 - 18:00 lectures, commercial presentations  
19:00 banquet

## Friday, October 6, 2017

9:00 - 13:00 lectures, commercial presentations  
13:00 - 13:30 closing ceremony

### Chairman of the Scientific Committee:

Prof. Ing. Jan Šmidrkal, CSc., VŠCHT v Praze

### Members :

Doc. Ing. Jarmila Hojerová, PhD., STU Bratislava

Doc. Ing. Rahula Janiš, CSc., UTB ve Zlíně

RNDr. Hana Bendová. PhD., SZU Praha

Ing. Radek Hanek

Official languages of the Conference are Czech, Slovak and English. Lectures will be simultaneously interpreted in English or Czech.

### Publishing of contributions:

Scientific programme of the Conference will be compiled by the Committee from submitted contributions. The presentations will be published in the Conference proceedings ( ISBN ) and distributed to all participants at the registration.

### Information for authors:

Text of the contribution should be sent by e.mail in the maximum extent of 4 pages ( including figures and graphs) to [radekhanek@seznam.cz](mailto:radekhanek@seznam.cz). The final text will be minimized to the format A5 before publishing.

**Deadline for registering the presentations :** **2.6.2017**

**Deadline for full text submission:** **15.9.2017**

## ORGANIZATION

**Accommodation** is organized in the Hotel Galant Mikulov (<http://www.galant.cz>)

**Conference fee** is 350,- euro for the participant and includes proceedings, accomodation, catering, other organizing and matherial costs. The conference fee should be paid by bank transfer.

**Deadline for the payment: 31.8.2017** after this deadline the application will be automatically cancelled without notice.

### Bank details:

Bank: Komerční banka Praha

Account no: 19-580 699 0237/0100

IBAN: CZ1301000000195806990237

SWIFT: KOMBCZPPXXX

**Registration** : Forward the registration forms to the bellow stated address, please:

**Conference Secretary:** Ing. Jana Kubelová

**Address:** Kosmetologická společnost ČR Vyšehradská 2, 128 00 Praha 2, Czech Republic

**E.mail:** [jana.kubelova@aroma.cz](mailto:jana.kubelova@aroma.cz)

**tel:** +420 778 403 690

**fax:** +420 241 481 798

**Deadline for the registration :** **31.7.2017**

**Exhibition:** The conference will comprise an exhibition of products and matherials in the room close to the lecture hall.

The fee for the exhibition is 9.000,- CZK per company

**Those interested should register and pay by 31.8.2017**

## KEY DATES RECAPITULATION

The Conference will be held:	4.-6. Oct. 2017	Submission of applications:	31.7.2017
Registration of papers and company presentation :	2.6.2017	Conference fee payment:	31.8.2017
2nd circulary will be distributed :	20.6.2017	Exhibition fee payment:	31.8.2017
		Sumbission of presentations:	15.9.2017

# A LIST OF LECTURES

Hojerová J., Beránková M., Melegová L.:

Účinek bariérových látek voči dermálnemu prieniku pesticídov používaných záhradkármi/  
Effect of barrier substances against dermal penetration of pesticides used by gardener

Šmidrkal J.:

Antimikrobiální vlastnosti derivátů karboxylových kyselin/  
Antimicrobial properties of carboxylic acids derivatives

Janiš R.:

Radiofrekvenční liposukce/  
Radiofrequency liposuction

Dastychová E.:

Aktuální kontaktní alergeny kosmetických přípravků/  
Actual contact allergens in cosmetics products

Jírová D., Chrz J., Kejlová K., Bendová H.:

Zázraky micelárních vod/  
Miracles of micellar fluids

Bendová H., Jírová D.:

Metody zkoušení kosmetických výrobků/  
Methods of analysis necessary for checking the composition of cosmetic products

Dolečková I.:

„Anti-pollution“ kosmetika a její testování/  
Anti-pollution cosmetics and testing

Machová L., Dolečková I.:

A comprehensive in vivo study of Caucasian facial skin parameters on 486 male and female

Marešová M.:

*In vivo* reflektanční konfokální mikroskopie pro studium účinnosti kosmetických přípravků/  
*In vivo* reflectance confocal microscopy in testing of cosmetic products

# A LIST OF LECTURES

Letašiová S.:

Hodnocení kožní senzitivace vybraných kosmetických surovin s použitím rekonstruovaného modelu lidské kůže EpiDerm a Interleukin 18 /Assesment of the skin sensitization of selected cosmetic ingredients using reconstructed human skin model EpiDerm and Interleukin 18

Smílek J.:

Charakterizace kosmetických přípravků fyzikálně-chemickými metodami/  
Physical-chemical methods for characterization of cosmetics products

Matoušková P.:

Příprava a charakterizace moderních kosmetických přípravků s antimikrobiálním účinkem/  
Preparation and characterization of modern cosmetics products with antimicrobial effects

Rudolf O.:

Kovové ionty v olejích/  
Metal ion in oils

Egner P.:

Využití révy vinné pro kosmetické účely/  
Grapevine for cosmetics purposes

Mencner M.:

Multifunctional Sensory Ingredients for Skin Care Formulations

Martinez B., Rubio E., Siekierski M.:

Mitophagy activation, a novel anti-aging cosmetic target

Klimczyk-Caryk M., Zalesińska W., Klkowski L., Drobnik A.:

The Effect of Series of General-Butterfly-Crystally Treatment, Treatments on the Quality of Skin

Kaminski D., VITADENIA :

Active ingredient from Tahitian stem cells to skin rejuvenation

Overath M.:

Create Versatility, Maintain Stability, Formulation all-rounders with many talents

Pikal P.:

Doporučení RAC pro TiO<sub>2</sub> ve světle rizik, aneb je třeba se obávat použití nano TiO<sub>2</sub>?/

Recent RAC opinion about TiO<sub>2</sub> in light of real risks, should you be worried about exposure to nano TiO<sub>2</sub>?